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Mission-Profile-Based Lifetime Prediction for a SiC MOSFET Power Module using a Multi-Step Condition-Mapping Simulation Strategy

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Abstract- The reliability analysis and lifetime prediction for SiC-based power modules is crucial in order to fulfill the design specifications for next-generation power converters. This paper presents a fast mission-profile-based simulation strategy for a commercial 1.2 kV all-SiC power module used in a photovoltaic (PV) inverter topology. The approach relies on a fast condition-mapping simulation structure and the detailed electro-thermal modeling of the module topology and devices. Both parasitic electrical elements and thermal impedance network are extracted from the finite-element analysis of the module geometry. The use of operating conditions mapping and look-up tables enables the simulation of very long timescales in only a few minutes, preserving at the same time the accuracy of circuit-based simulations. The accumulated damage related to thermo-mechanical stress on the module is determined analytically and a simple consumed lifetime calculation is performed for two different mission profiles and compared in different operating conditions.

I. INTRODUCTION

Silicon Carbide (SiC) power devices and modules are increasingly emerging in the design of power electronic converters [1, 2]. This is mainly due to their promising high temperature and high frequency operative capability [3]. SiC modules find advantage in those applications where high efficiency, more integration and higher power density are prioritized, and can pay off the higher cost of such devices [4]. The SiC MOSFET is now an established device in terms of manufacturing and many off-the-shelf products are available, rated up to 1.7 kV and 500 A [5]. Nevertheless, despite their inherent advantages, fulfilling the converter design specifications is still a challenge for many applications, with increasing demand for reliability and cost constraints. Higher current density capability,

together with higher thermal conductivity, determines higher temperature variations in SiC devices in comparison to Si devices rated at the same power. Therefore, the lifetime prediction of SiC devices becomes a critical issue in the design of emerging power electronic converters.

Substantial efforts have been invested in the reliability prediction of grid-connected converters, especially for photovoltaic (PV) and wind energy generation [6–8], an emerging field for SiC devices. Most of the component-level reliability prediction methods are based on the Military-Handbook-217F [9]. The methods in such handbooks are easy-to-use, but may not be suitable for the design of components in real field operation, since they are based on constant failure rates and components wear-out is neglected. In addition, on the FIDES guide [10], accelerated factors for different stressors, e.g. temperature and humidity, have been provided, also including several wear out failure mechanisms. By the way, the data provided in FIDES are limited to a few components, e.g. IGBTs and capacitors, but without making a difference between different technologies and manufacturers. Thus, a more specific component-level reliability analysis and the impact of real field mission profiles have to be considered. A very thorough and innovative multi-timescale stress modeling approach has been presented at Aalborg University in 2015 by Ma *et al.* in [11, 12], introducing the possibility to step through different time constants (electrical, thermal and mechanical) for the analysis of power converter loading profiles. Several other studies, e.g. [13–17], have studied mission-profile-based approaches for Si IGBT modules. Still, a limited amount of research works [18]–[20] have applied it to SiC devices using accurate electro-thermal and device modeling.

In addition, the challenge in lifetime prediction is to identify the failure and degradation mechanisms and their modeling [21, 22]. The main long-term failure mechanisms of power semiconductor modules is the bond

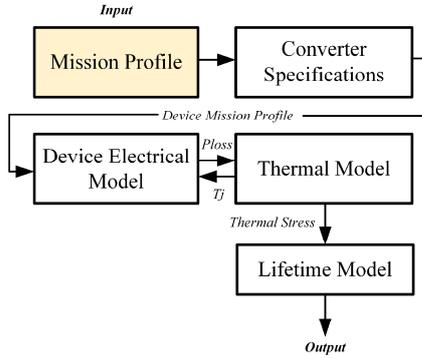


Fig. 1. A general mission-profile-based electrothermal simulation workflow.

wire and solder fatigue due to temperature-induced mechanical stress. The degradation process has been extensively studied in the case of Si IGBT modules and several lifetime modeling techniques have been introduced, both physical [23] and empirical [24]. Nowadays, the wire bonding packaging technology for commercial SiC MOSFET power modules is, in fact, identical to the one widely used for Si IGBT modules. Therefore, the same degradation and failure mechanisms have been observed in [25], and bond wire damage, together with die-attach degradation, are still the predominant cause of thermal-related failure and aging. Nevertheless, the device and material physical characteristics – especially thermal properties – are significantly different. SiC technology relies on smaller and power-dense chips, which can undergo a considerably heavier thermal stress. Therefore, new physics-based models are needed for both device and power module, in order to properly estimate their reliability.

This paper's structure is the following: Section II explains the challenges related to the mission-profile-based lifetime prediction and Section III presents the proposed modeling and simulation approach. In Section IV the strategy is applied to a three phase grid-connected PV inverter chosen as a case study. The results and validity of this methodology are discussed in Section V and final remarks are provided in Section VI.

II. MISSION-PROFILE-BASED LIFETIME PREDICTION STRATEGY

The lifetime prediction of a power module requires a comprehensive set of elements: 1) a semiconductor device model that can accurately estimate the power loss in a wide range of operating conditions, including high temperature; 2) the electrical model has to describe properly the packaging-related parasitic elements, which can significantly influence the overall power loss; 3) a

thermal model capable of estimating the temperature stress throughout the module's lifetime; 4) a reliability lifetime model describing one or more physical failure or degradation mechanisms taking place inside the module; 5) a damage accumulation method to calculate the consumed lifetime and the degradation of the device parameters. Advanced multi-physics simulation tools based on Finite Element Analysis (FEA) offer outstanding accuracy, but their huge computational cost would make it impractical to simulate millions of switching events. On the contrary, compact electro-thermal circuit models can be very fast, with a small percentage loss in accuracy. All these elements have to be specifically tuned on the particular case study and necessary approximations and assumptions have to be worked out to speed up the simulation process without losing accuracy.

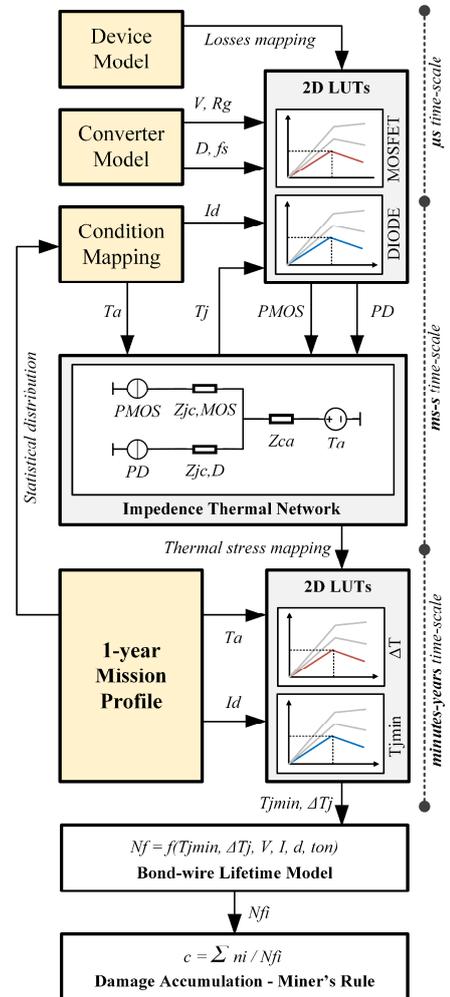


Fig. 2. Proposed mission-profile-based electrothermal simulation strategy.

A. Mission-Profile-Based Simulation Challenges

During the normal operating lifetime of a converter, a power device may experience deep changes in its working conditions, depending on the load cycle (mission profile) required for the specific application, and the external conditions, i.e. ambient temperature variations. Fig. 1 depicts the general workflow for mission-profile-based electrothermal simulation aimed to reliability analysis [11]. The design of a converter topology with determined specifications and the selection of a device or module capable of handling the required load cycle, working within the safe-operating area (SOA), is driven by a mission profile study. A converter model with a defined switching pattern is selected and thus the mission profile can be translated into the equivalent device loading, as presented in [17]. Many examples of electrothermal device simulation using compact or behavioral models are available in literature [26–29]. The typical approach is the use of compact or behavioral electrical device models in conjunction with a heatsink thermal model. The obtained thermal stress is thus translated in lifetime consumption by means of a lifetime model [11]. The major obstacle for such methods is the millions of switching events occurring during the lifetime of a device. The simulation of a long mission profile is unachievable because of the large mismatch in device, converter, heatsink and mission profile time constants, as presented in detail in [11]. The huge gap between different timescales can be overcome by using condition mapping and multi-timescale simulation, as presented in [11, 16]. In these works, the single device and system simulations were decoupled by operating an offline calculation of the power losses to create lookup tables (LUTs). Analytical losses models [30] or co-simulation [31] can also be used for this purpose. Instead of running a circuit simulation for every switching cycle, an averaged value of power losses can be calculated from the LUT and injected into a lumped thermal network. The estimated junction temperature is then used to close the loop (Fig. 1). This strategy has shown outstanding accuracy and simulation speed. This is effective for short mission profiles (<1 day), but not enough if the aim is the simulation of very long profiles

TABLE I – CONVERTER SPECIFICATIONS

Three-phase 2L-VSI design ratings	
Rated maximum power	$P = 20 \text{ kW}$
Input DC-bus voltage	$V_{DC} = 800 \text{ V}$
Switching frequency	$f_s = 50 \text{ kHz}$
Output frequency	$f_o = 60 \text{ Hz}$
SiC MOSFET module – CCS020M12CM2	
Blocking drain voltage	$V_{ds,max} = 1200 \text{ V}$
Maximum drain current	$I_{d,max} = 25 \text{ A}$

(months or years) due to the huge amount of data points and computational cost.

The proposed strategy, depicted in Fig. 2, aims to fill the gap between the medium and long timescales - while still preserving an accurate insight on the short timescale - by adding further steps into the condition mapping. In fact, by mapping the mission profile into a discrete range of operating conditions, only a small number of electrothermal simulations are required. The aim is to calculate the thermal stress for each condition – i.e. the minimum/maximum temperature and cycle amplitude ΔT_j – which is crucial for the lifetime prediction, and generate a second set of LUTs. These maps can be interpolated in order to find the thermal stress on each device for the considered mission-profile, as shown in Fig. 2. Additionally, the proposed strategy relies on a detailed physics-based temperature-dependent device model, validated through experimental data, and an accurate modeling of the thermal dynamics, by using a dedicated thermal network, extracted from FEM simulations. The following Section presents the application of the proposed method to a study case, exploring in a logical sequence the steps taken in the modeling, simulation and lifetime prediction.

III. LIFETIME PREDICTION OF A 1.2 kV SiC MULTI-CHIP POWER MODULE

The simulation strategy presented in Section II was applied to a case study comparing two real field mission profiles for PV applications. The profile consists in solar irradiance and ambient temperature, measured over one year span with a sampling rate of one minute. The case study is a typical state-of-the-art topology for PV applications, composed by a PV array, a boost converter, a three-phase grid-connected voltage source inverter (VSI) and an AC side filter. The concept topology is depicted in Fig. 3. The design ratings for the VSI are reported in Tab. I. The 3P-VSI inverter is embedded in a single full-SiC power module rated 1.2 kV and 25 A [32]. The presented lifetime prediction focuses on the bond-wires

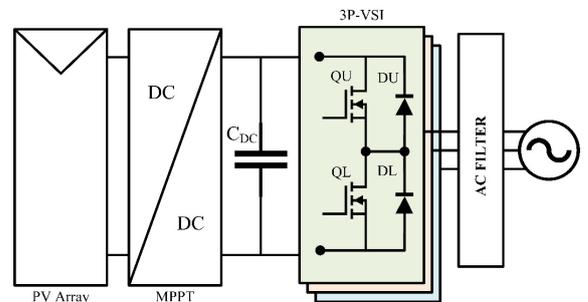


Fig. 3. State-of-the-art PV system circuit topology.

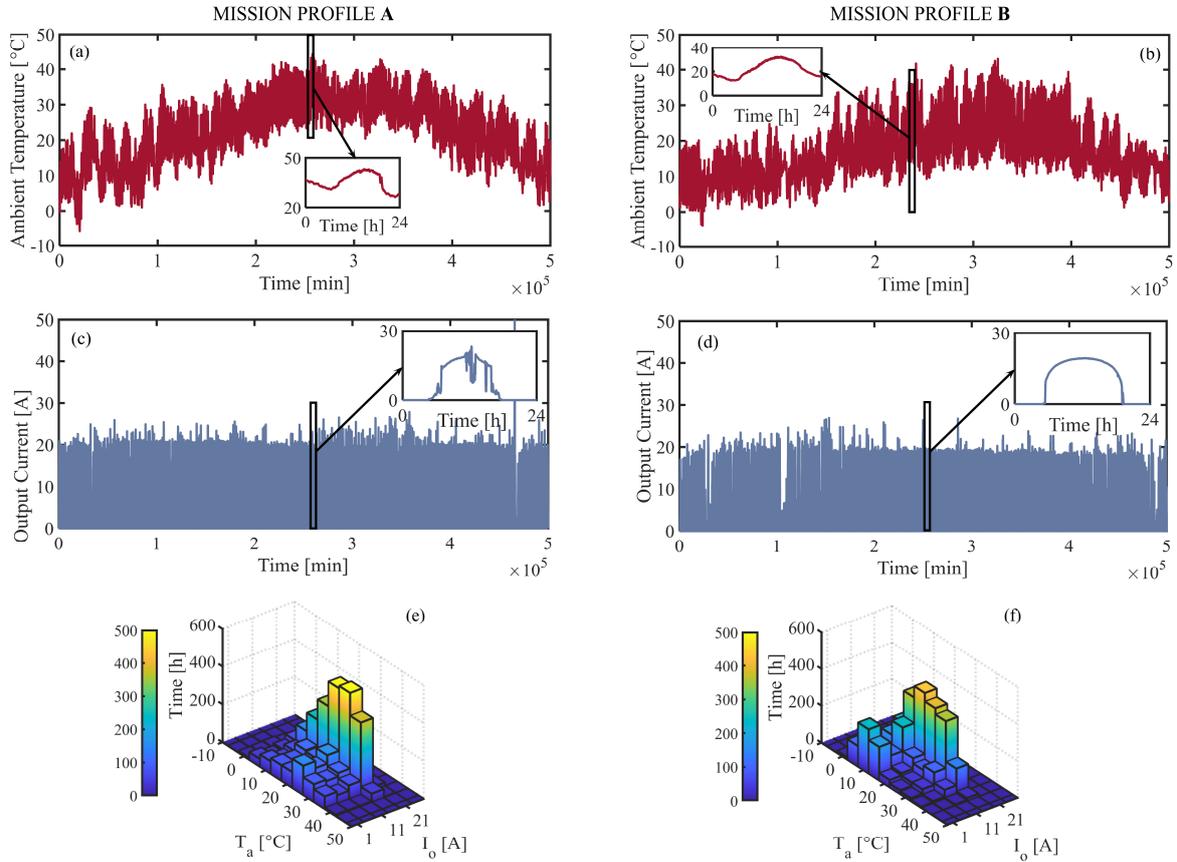


Fig. 4. Mission profile condition mapping: ambient temperature in MP-A (a) and MP-B (b); output current in MP-A (c) and MP-B (d); statistical distribution of operational conditions in MP-A (e) and MP-B (f).

interconnections only, which means that solder layer delamination and other wear phenomena have been neglected in this analysis. It is worth to note that the specific design and modeling of the remaining sub-components of the PV system are out of the scope of this paper. Assuming that the maximum available power is always transferred to the VSI, the solar irradiance

sequence can be translated into an output load current profile I_o .

A. Mission-profile mapping

Depending on the length of the chosen mission profile (MP) and its time resolution, a frequency distribution of the operating conditions can be made in terms of ambient

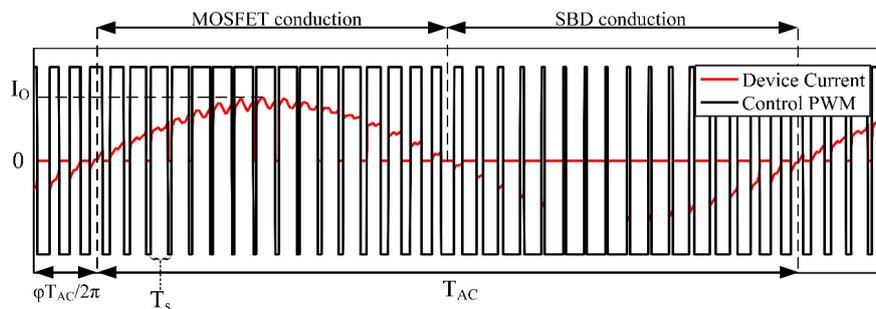


Fig. 5. 2-level SPWM switching pattern and output current for a generic power switch.

temperature T_a and load current I_o . Each combination of T_a and I_o is charted in a 2D frequency histogram. The mapping of such large amount of data into a discrete range of values is extremely helpful to reduce the overall simulation time. In Fig. 4, the two considered PV mission profiles – MP-A from a site in Arizona and MP-B from a site in California - are mapped with 5°C and 5 A grid resolution. The resulting bins describe the occurrence of each range of operating conditions for both the MPs (Fig. 4.e-f).

B. Converter Model

Fig. 5 shows the sinusoidal PWM switching pattern for a generic electronic switch in a 3P-VSI and the relative device current. It is possible to work out an analytical model of the converter in order to extract the correct load current and duty-cycle fed to the losses LUTs for each of the switches. The duty-cycle DC is calculated as in (1),

$$DC^n = \begin{cases} DC_{MOS}^n = \frac{1}{2}[1 + M \cdot \sin(2\pi f_{AC} \cdot nT_s)] \\ \quad \text{if } 0 \leq nT_s < \frac{T_{AC}}{2} \\ DC_{SBD}^n = \frac{1}{2}[1 + M \cdot \sin(2\pi f_{AC} \cdot nT_s)] \\ \quad \text{if } \frac{T_{AC}}{2} \leq nT_s < T_{AC} \end{cases} \quad (1)$$

where M is the modulation index. For each period of the AC output current T_{AC} , the average total power losses P_{tot} during the n-th switching period T_s are given by (2),

$$P_{tot}^n = \begin{cases} V_{on,MOS}^n(T_j^n) \cdot I_o^n \cdot DC_{MOS}^n + E_{sw,MOS}(I_o^n, T_j^n) \cdot f_s \\ \quad \text{if } 0 \leq nT_s < \frac{T_{AC}}{2} \\ V_{on,SBD}^n(T_j^n) \cdot I_o^n \cdot DC_{SBD}^n + E_{sw,SBD}(I_o^n, T_j^n) \cdot f_s \\ \quad \text{if } \frac{T_{AC}}{2} \leq nT_s < T_{AC} \end{cases} \quad (2)$$

where the instantaneous conduction power loss, dependent on the on-state voltage drop $V_{on}(T_j)$ and the output current I_o , is multiplied by the duty-cycle to obtain an average per switching period. E_{sw} is the switching energy (turn-on + turn-off), also dependent on I_o and T_j , for a given DC bus voltage and gate resistance. The MOSFET conducts during the first half of T_{AC} , whereas the SBD conducts in the second half. For the n-th T_s , I_o can be approximated as in (3),

$$I_o^n = I_o \sin[2\pi f_{AC} \cdot nT_s + \varphi] \quad (3)$$

where φ is the phase shift between voltage and current.

C. Electrical Device Model

The total power losses (conduction + switching) for each kind of device in the module (*PMOS* and *PD*) have to be mapped for a certain range of output current I_o and junction temperature T_j . A fixed DC-bus voltage V_{DC} and gate drive resistance R_g are set. This calculation is performed offline using a temperature-dependent electrical device model and generating 2D LUTs.

The SiC power module considered in our case study contains six SiC MOSFETs chips (CPM2-1200-0080B part number) and six freewheeling SiC Schottky Barrier Diodes (SBDs) chips (CPW4-1200-S020B SiC SBD part number). The device modeling was carried out in the SABER environment, using the Power MOSFET tool released by Synopsys in 2017. The tool relies on the SiC Power MOSFET model released in 2016 at University of Arkansas [33] and derived from the model developed in 2007 by McNutt *et al.* [34]. The model is physics-based and features several temperature-dependent parameters, which were extracted from the measured static characteristics using the Power MOSFET tool. The tool identifies these parameters using DC *I-V* curves, *C-V* curves, and diode forward/reverse characteristics. The full model and parameters description was omitted here for conciseness. However, the on-state resistance of the SiC MOSFET, which determines the conduction power loss, is defined by (4) [34].

$$R_{ds} = \frac{W_{dsj} - W_d}{qAN_d\mu_n} + R_s \quad (4)$$

TABLE II – DEVICE MODEL PARAMETERS

Parameter	Value	Unit	Temp. Dep.
CPM2-1200-0080B SiC MOSFET			
C_{gs}	Gate-source capacitance	2.8e-9	F No
C_{ox}	Gate oxide capacitance	2.13e-9	F No
W_b	Cell width	0.00015	cm No
W_{dsj}	Drain-source depletion region width	voltage dep.	cm Yes
W_{gdj}	Gate-drain depletion region width	voltage dep.	cm Yes
N_d	Drift region dopant density	2.2e16	cm ⁻³ No
μ_n	Drift region carrier mobility	890	cm ² V ⁻¹ s ⁻¹ Yes
A	Device active area	0.1667	cm ² No
A_{gd}	Gate-drain overlap area	0.019	cm ² No
A_{ds}	Drain-source overlap area	0.1477	cm ² No
R_s	Substrate resistance	0.002	Ω Yes
V_T	Gate threshold voltage	3.3	V Yes
CPW4-1200-S020B SiC SBD			
R_d	On-state resistance	0.0296	Ω Yes
V_d	On-state resistance	0.931	V Yes
n	Ideality factor	7.09	No
R_{rk}	Terminal resistance	1373.6	No
R_{rtau}	Temp. scaling factor	12.4e-9	No

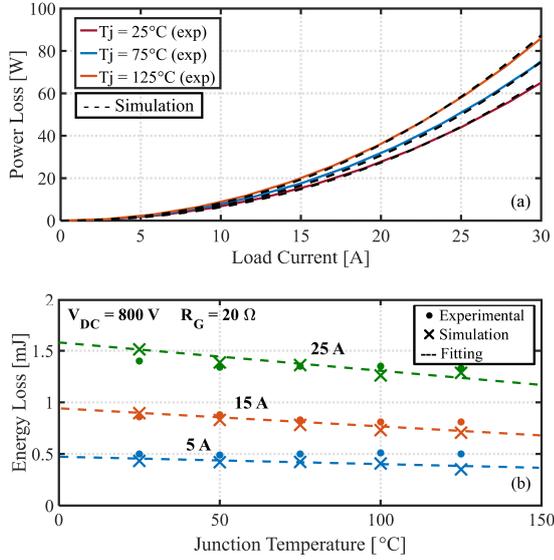


Fig. 6. Validation of MOSFET's conduction power loss vs. load current at different temperatures (a), and total switching energy loss vs. junction temperature for different drain current values (b).

(5) determines the values of the MOSFET internal capacitances C_{ds} and C_{gd} , characterizing the switching power loss.

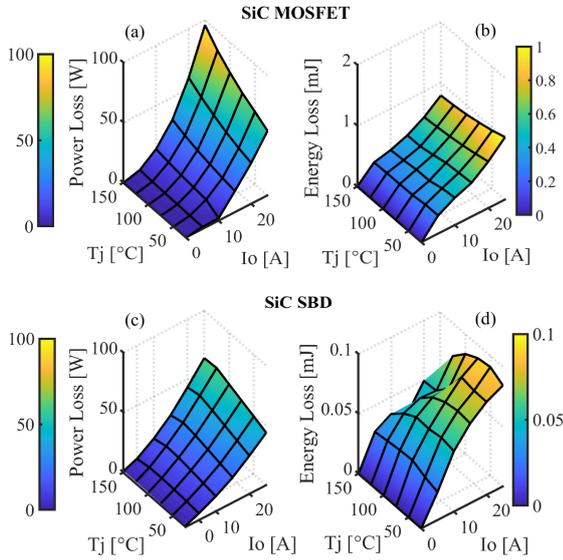


Fig. 7. Condition mapping of: conduction power losses (a) and switching energy losses (b) maps for the SiC MOSFET; conduction power losses (c) and switching energy losses (d) maps for the SiC SBD.

$$C_{ds} = \frac{A_{ds}\epsilon_{SiC}}{W_{dsj}} \quad C_{gd} = C_{ox} \parallel \frac{A_{gd}\epsilon_{SiC}}{W_{gdj}} \quad (5)$$

The meaning of each parameter and their extracted values – together with other important parameters for the MOSFET and the SBD – are reported in Tab. II. Additionally, the table shows whether or not each parameter featured in the model is temperature dependent.

The parasitic parameters for each inverter leg in the module have been extracted from FEM simulations in ANSYS Q3D and successively imported into the compact model. An equivalent parasitic impedance matrix has been extracted for each of the conductive paths in the module.

The SiC MOSFET conduction losses for increasing load current at different temperatures have been validated with experimental static measurements from a B1505A Keysight curve tracer and a hotplate and are shown in Fig. 6.a. The switching energy losses have also been validated by means of a double-pulse test (DPT) setup, with 5 to 25 A current and 25°C to 125°C junction temperature range. The comparison of simulated switching energy losses and test results are provided in Fig. 6.b, with the test conducted at 800 V DC-bus voltage and $20\ \Omega$ gate drive resistance. Less than 2% relative error is observed in the conduction losses estimation and less than 10% in the switching energy one. The temperature- and current-dependent power losses for both SiC MOSFET and SiC Schottky diode have been mapped by means of the SABER electrical device model and reported in the 3D plots in Fig. 7. The conduction losses have been extracted from the static characteristics of the devices.

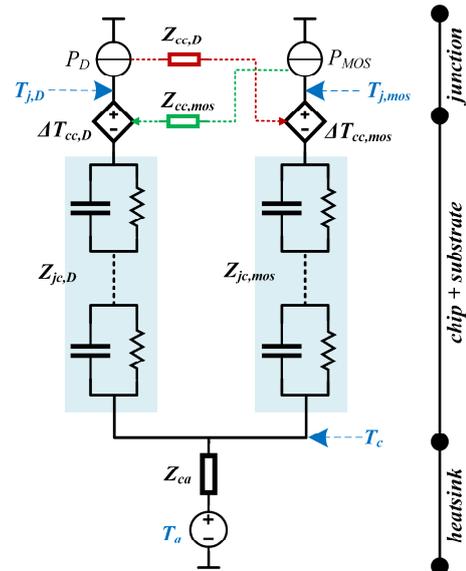


Fig. 8. Lumped-impedance thermal network.

D. Thermal Impedance Model

The thermal model shown in Fig. 8 can be used for estimating the device junction temperature. The main assumption is a unidirectional heat-flow from the device junction to the heatsink through the thermal stack material. The model features the power injection from both the diode and the SiC MOSFET (respectively PD and PMOS), the relative junction-to-case impedances $Z_{jc,D}$ and $Z_{jc,MOS}$ and the case-to-ambient impedance Z_{ca} which describes the heatsink thermal properties. The two junction-to-case impedances, accounting for the chip and substrate thermal behavior, can be modeled as lumped multilayer Foster networks. This kind of thermal model represents analytically the thermal transient response of the module. The transient thermal impedance $Z_{\theta}(t)$ between two points can be described by (6),

$$Z_{\theta}(t) = \frac{\Delta T(t)}{P(t)} = \sum_{i=1}^n R_{\theta,i} \left(1 - e^{-\frac{t}{R_{\theta,i} C_{\theta,i}}} \right) \quad (6)$$

where ΔT is the temperature difference between the two points, P is the injected power and the R_{θ} and C_{θ} coefficients are the elements of the equivalent RC chain network. Additional impedances in the network can model the 3D thermal cross-coupling effects taking place between nearby chips – e.g. impedances $Z_{cc,D}$ and $Z_{cc,mos}$ in Fig. 8 [35]. The thermal impedance values can be obtained in several ways: 1) based on the datasheet from the module manufacturer; 2) from the thermal characterization of the module by observing experimentally the heating/cooling thermal response to a power pulse injection; 3) the same process can be emulated in a finite-element method (FEM) simulation of the module and the fitting of thermal response curves, as shown in [36, 37].

A Foster-type multilayer impedance network was extracted from the transient thermal simulation of the

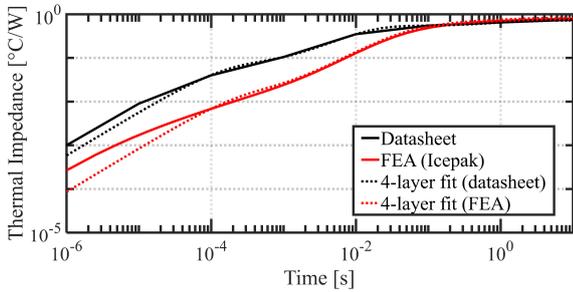


Fig. 9. Comparison of the transient thermal impedance characteristics from the module datasheet and the FEM simulation in ANSYS Icepak.

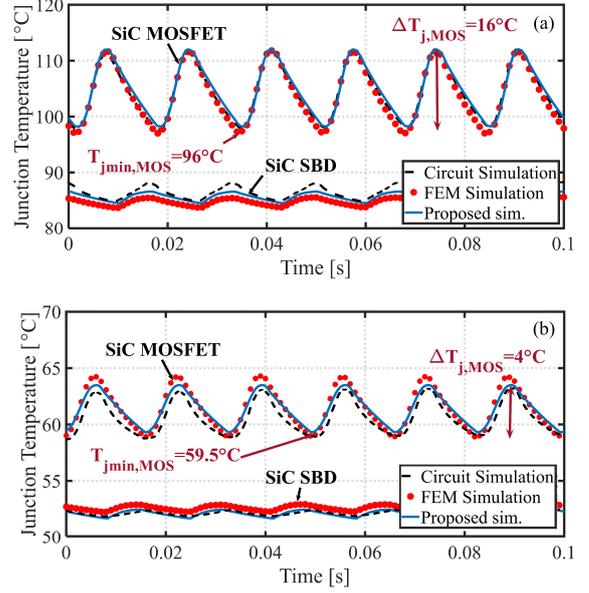


Fig. 10. Comparison of the steady-state AC-frequency junction temperature fluctuation obtained from FEM simulation (ANSYS), circuit simulation (Saber), and proposed fast simulation (Simulink) for (a) $T_c=80^\circ\text{C}$, $I_o=25\text{ A}$ and (b) $T_c=50^\circ\text{C}$, $I_o=15\text{ A}$.

module geometry in ANSYS Icepack. In Fig. 9, the obtained transient thermal impedance has been compared with the one reported in the module datasheet. The plot also shows the mathematical fitting of both the curves. The junction-to-case section contains four RC elements while the case to ambient is modeled as one single RC element. The same thermal network elements have been used for each of the six MOSFET/diode couples in the module.

A visual comparison of the proposed fast simulation strategy based on LUTs, a circuit simulation in SABER and a FEM thermal simulation in ANSYS Icepack is provided in Fig. 10. The same power losses injected in the LUTs were used as power source for the FEM simulation. The junction temperature was measured on the top surface and in the middle of each chip, where the junction is. The proposed strategy is implemented in MATLAB/Simulink. The same thermal network was used to estimate the junction and case temperature. The simulated topology is the full 3P VSI, operating at 20 A (Fig. 10.a) peak load current and 15 A (Fig. 10.b). The ambient temperature was fixed at 80°C (Fig. 10.a) and 50°C (Fig. 10.b) and no heatsink was used ($T_a = T_c$), in order to accelerate the convergence to a steady-state condition for the FEM simulation. While in the SABER circuit simulation (2 ns step-time) the instantaneous power losses from the device compact models are injected into the thermal network in the proposed strategy, the power loss is averaged over each switching period. The obtained steady-state

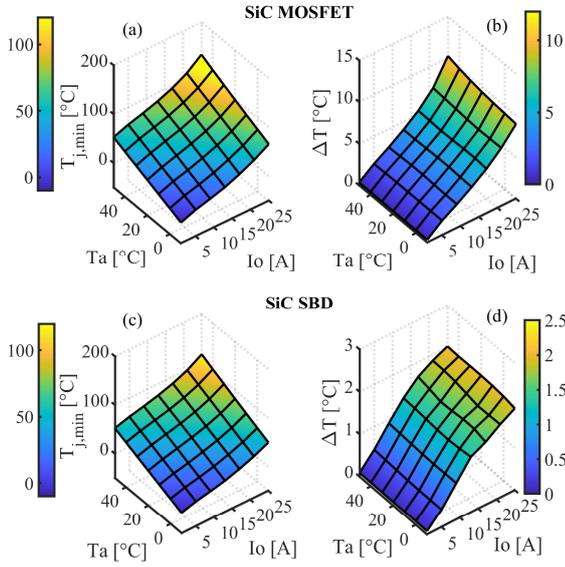


Fig. 11. Thermal stress condition mapping for AC thermal cycling: minimum junction temperature (a) and thermal cycle amplitude (b) for the MOSFET; minimum junction temperature (c) and thermal cycle amplitude (d) for the SBD.

temperature estimation shows outstanding agreement between the three simulation strategies, proving that the accuracy loss originating from the use of LUTs is not particularly significant. While the circuit simulation took about 7 min to converge and the FEM simulation about 10 min (1 ms step-time), the proposed simulation strategy only took about 5 s (100 μ s step-time). This represents a huge gain in computational speed.

Each combination of T_a and I_o throughout the mission profile, results in a different steady-state junction temperature T_j cycling for the device. It is assumed here that the steady-state lasts for the whole mission-profile sampling time step, before the operating conditions change. This assumption is legit, since the thermal time constant (seconds) is generally much shorter than the slow changes occurring in the mission profile.

The thermal behaviors of both MOSFET and diode have been mapped simulating the inverter operation for each combination of T_a and I_o , in the same grid used to map the mission profile. The simulation was performed using the proposed approach in MATLAB/Simulink. A case to ambient thermal impedance of 0.3 K/W was used to model the heatsink. Therefore, the case temperature is not assumed constant in the mapping process. The steady-state minimum junction temperature $T_{j,min}$ and thermal cycle amplitude ΔT_j (defined as shown in Fig. 10) for each of the operating points were collected in 2D maps, plotted in Fig. 11. Hence, the maps are used as LUTs and

interpolated to determine the thermal stress on MOSFET and SBD for each point of the mission profile.

It is worth to note that the whole mapping of the steady-state thermal stress conditions takes about 2 minutes simulation time, with the chosen grid. This time might increase in case a finer mapping grid is used, or decrease in the opposite case, since the number of simulations required is changing.

Once the $T_{j,min}$ and ΔT_j for the whole mission have been calculated, the consumed lifetime or damage for each time-step can be predicted by using a lifetime model. The damage can be accumulated to calculate the overall consumed lifetime. The chosen reliability model will be presented in the next section.

E. Lifetime modeling and damage accumulation

Several studies have investigated the reliability of power modules by using accelerated test methods. A large number of IGBT modules was tested across a wide range of conditions during the LESIT project [38], providing an extensive data set for thermal reliability analysis of bond wires. The data is fitted by means of (7), a simple empirical equation, similar to the Coffin-Manson one used in [14], used to calculate the number of cycles to failure N_f under a certain stress condition.

$$N_f = A \cdot (\Delta T_j)^{-\alpha} \times \exp\left(\frac{E_a}{k_b T_{jm}}\right) \quad (7)$$

The equation contains the dependence on the junction temperature cycle amplitude ΔT_j and the mean junction temperature T_{jm} . E_a is the activation energy, k_b is the Boltzmann constant and A and α are curve fitting parameters. A more recent and refined empirical model (widely known as the ‘‘Bayerer’s model’’) was presented in [24], featuring the impact of the heating time t_{on} , the current per wire I , the blocking voltage V and the wire diameter d . In addition, the minimum junction temperature $T_{j,min}$ is considered. All the β coefficients are empirical and derived from curve fitting.

$$N_f = A \cdot (\Delta T_j)^{-\beta_1} \cdot \exp\left(\frac{\beta_2}{T_{j,min} + 273}\right) \cdot t_{on}^{\beta_3} \cdot I^{\beta_4} \cdot V^{\beta_5} \cdot d^{\beta_6} \quad (8)$$

The modules used in the accelerated testing have rating and technology comparable to the one in our case study. This model offers tolerance margins for each of the parameters, which can be useful for the overall error calculation of the proposed method. Therefore, the model shown in (8) is applied in this study.

A linear cumulative damage model, i.e. the Miner’s rule (9), is used for the lifetime prediction. The assumption of this model is that the damage on the modules is

TABLE III – 1-YEAR ACCUMULATED DAMAGE

	SiC MOSFET bond-wire damage	SiC SBD bond-wire damage
MP-A	0.026 (2.6%)	$<10^{-2}\%$
MP-B	0.01 (1%)	$<10^{-2}\%$

independent of the stresses experienced during its life cycle [39].

$$c = \sum_i \frac{n_i}{(N_f)_i} \quad (9)$$

Where n_i is the number of temperature cycles the device spent under a certain stress condition and N_f the number of cycles to failure under the same stress.

The thermal stress on power modules has basically two sources: the ambient temperature fluctuation and the variation of load condition for the power devices. The first causes a slow thermal cycling, with dynamics in the minute-range timescale, whereas the second causes a fast thermal cycling, usually in the sub-second timescale, e.g. at line frequency. According to the study in [40], the degradation of bond-wires heavily depends on the fast thermal cycling stress, whereas the slower dynamics, due to ambient temperature variations, affect the die-attach. It has been demonstrated in [17] that the low slow thermal cycling has minimum role in the lifetime consumption calculation for bond-wires. Including the consumed lifetime calculation due to die-attach degradation would require an additional cycle counting algorithm and

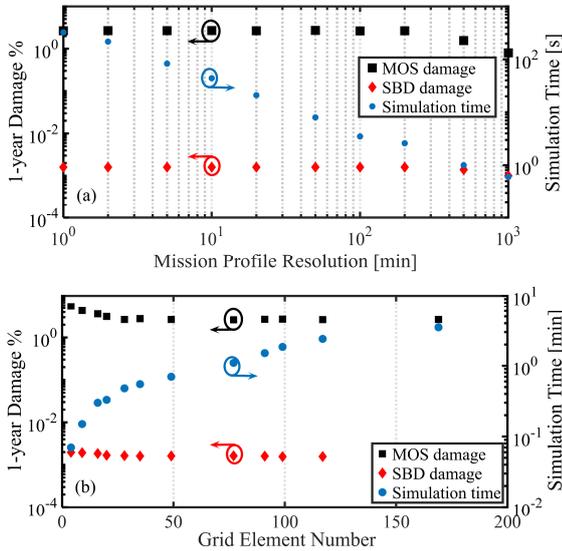


Fig. 12. Impact of MP resolution (a) and of thermal stress mapping resolution (b) on the 1-year damage prediction and the simulation time for MP-A.

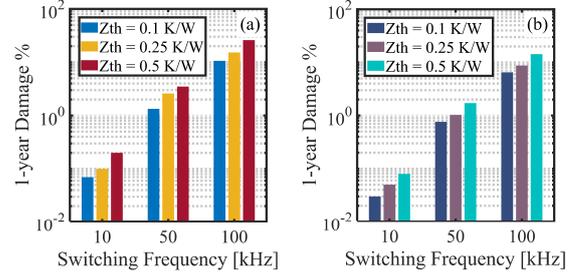


Fig. 13. Impact of the switching frequency on the 1-year damage prediction for MP-A (a) and MP-B (b).

therefore, it has not been included in this study for conciseness.

Using the model in (8), the line-frequency thermal cycling consumed lifetime has been calculated and accumulated using the Miner's rule. Tab. III reports the estimated damage on the bond-wires of both SiC MOSFET and SBD after one-year for both the considered MPs. The chosen heatsink thermal impedance in this case was 0.25 K/W.

As expected, the low thermal stress on the SBD chips results in a very low accumulated damage. Thus, the MOSFET chips' bond-wires are the ones experiencing most of the aging. Additionally, MP-B, despite being quite similar to MP-A, shows significantly lower impact on the device lifetime.

It is interesting to observe how the resolution (time-step) used in MP-A affects the simulation time and the resulting damage prediction. Fig. 12.a shows that decreasing MP-A resolution (i.e. increasing the time-step) from 1 min to 1-2 hours does not significantly influence the damage prediction, while drastically reducing the simulation time from 5 min to around 10 s. However, further decrease in the resolution determines less accurate predictions. Moreover, a trade-off between accuracy and simulation time can be obtained by choosing a proper grid resolution for the mapping of the thermal stress (as in Fig. 11). As one can observe in Fig. 12.b, increasing the number of grid elements, i.e. the mapping resolution, beyond approximately 50, does not affect the lifetime prediction, while visibly increasing the simulation time. Additionally, the consumed lifetime has been calculated for a range of different operating conditions. Fig. 13 shows how the variation of the switching frequency and the heatsink thermal impedance affects the damage prediction for both the MPs. This kind of comparative analysis can be easily performed using the proposed strategy. Reliability-wise optimization of a certain design in respect to one or more parameters is possible in relatively short simulation time and can also be automated.

IV. DISCUSSION

It is worth to note that the predicted lifetime consumption only concerns the bond-wires degradation, which is only part of the damage accumulated by the module. Many failure mechanisms contribute to the end-of-life of a power module, including damage due to single abnormal events, e.g. short circuit or overvoltage, which could occur during the device lifetime. The module's lifetime depends on the accumulation of the damage resulting from each of these failure mechanisms. Absolute life prediction is hard and involves a great number of uncertainties. Calculating the estimation error in the electrical and thermal models is possible, while it is more difficult to identify the tolerance for a lifetime prediction and goes beyond the scope of this work. The results provided in this analysis should therefore be taken as an indicator of the factors involved in the lifetime estimation process and the demonstration of a fast prediction strategy resulting from accurate electro-thermal modeling for the device, the module and the topology. Nevertheless, the final consumed lifetime prediction can be rather useful when comparing different design solutions and evaluating the one with the best reliability performance for the given mission profile. In these terms, the presented strategy can boost the reliable design of power electronic systems.

The degradation of several parameters takes place during the lifetime of a power module. The package-related degradation mostly influences the die and bond-wire attach. The chip also undergoes aging, which results in increased gate voltage threshold. The influence of such degradation on the considered SiC module was measured in [25], while in [41] the drift of on-state voltage for bond-wire and chip was measured separately during accelerated tests. Whether this degradation should be taken into account or not in the simulation process, depends on the entity of the on-state voltage drift, which could worsen the power loss generation. In the case considered here, the consumed lifetime during the mission profile is so low that the impact of parameter degradation on the loss would be, in total, less than 1%. When applying longer or more severe loading to the device, this degradation should be taken into account. The influence of parameter variation on the lifetime is estimated in [17] through Monte Carlo analysis.

V. CONCLUSION

A fast lifetime prediction strategy for the bond-wire interconnections of power semiconductor modules has been explored and presented in detail in this paper. An accurate physics-based electrical device model and thermal network have enabled an offline mapping of power losses and thermal behavior for a 1.2 kV three-

phase SiC power MOSFET/Schottky diode module. The temperature-dependent power losses have been validated through experimental data. A case study with a 20 kW PV inverter has been presented for the chosen module in order to clarify the proposed method application, in which the consumed lifetime due to the bond-wire degradation has been calculated for two different 1-year PV mission profiles. The use of LUTs has allowed the fast simulation of very large timescales in few minutes without compromising the accuracy and the comparative analysis of different design solutions. The proposed methodology can help the designer to assess the reliability of a power module and can be extended to any commercial device, provided the availability of proper technical documentation. Moreover, the process can be easily iterated to perform an automated optimization and extended to consider additional failure mechanisms. This strategy may be used for selecting among different part-numbers, optimizing in terms of electro-thermal performances, reliability and cost-effectiveness.

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